

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants : Patrick M. Martin, Matthew Lassiter, Darren Taylor, Michael Cangemi, and Eric Poortinga

Serial No. : To Be Assigned

Filing Date : September 9, 2003

For : PHOTOMASK HAVING AN INTERNAL SUBSTANTIALLY TRANSPARENT ETCH STOP LAYER

Art Group : To Be Assigned

Examiner : To Be Assigned

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
Washington, D.C. 20231

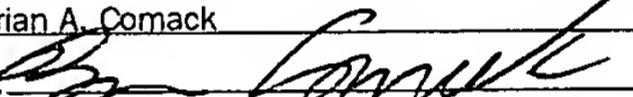
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Name: Brian A. Comack

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Pursuant to 37 C.F.R. §§§ 1.56, 1.97 and 1.98, applicants enclose herewith forms PTO/SB/08A and PTO/SB/08B containing references which may be deemed relevant to the above-identified application. Pursuant to the waiver of 37 C.F.R. 1.98(a)(2)(i) copies of only the non-patent literature are enclosed. The Examiner is respectfully requested fully to consider all of the enclosed items, and independently assess their teachings.

No fee is deemed necessary in connection with the filing of this Information Disclosure Statement. If any fee is required to preserve the pendency of the application, authorization is hereby given to charge the amount of any such fee to Deposit Account No. 01-1785.

Respectfully submitted,

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Dated: September 9, 2003
New York, New York
By: 
Brian A. Comack, Reg. No. 45,343

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| INFORMATION DISCLOSURE STATEMENT BY APPLICANT | | Application Number | TBA |
| (use as many sheets as necessary) | | Filing Date | September 9, 2003 |
| | | First Named Inventor | Patrick M. Martin |
| | | Art Unit | TBA |
| | | Examiner Name | TBA |
| Sheet | 1 | of | 2 |
| | | Attorney Docket Number | 67493/63 |

U.S. PATENT DOCUMENTS

| Examiner Initials* | Cite No. 1 | Document Number | Publication Date MM-DD-YYYY | Name of Patentee or Applicant of Cited Document | Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear |
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| Examiner Signature | Date Considered |
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¹ Applicant's unique citation designation number (optional). ² See Kinds Codes of USPTO Patent Documents at www.uspto.gov or MPEP 901.04. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). ⁴ For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵ Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. ⁶ Applicant is to place a check mark here if English language Translation is attached.

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| Substitute for form 1449B/PTO | | <i>Complete if Known</i> | |
| INFORMATION DISCLOSURE STATEMENT BY APPLICANT <i>(use as many sheets as necessary)</i> | | Application Number | TBA |
| | | Filing Date | September 9, 2003 |
| | | First Named Inventor | Patrick M. Martin |
| | | Group Art Unit | TBA |
| | | Examiner Name | TBA |
| Sheet | 2 | of | 2 |
| | | Attorney Docket Number | 67493/63 |

OTHER PRIOR ART -- NON PATENT LITERATURE DOCUMENTS

| Examiner Initials | Cite No. ¹ | Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published | T ² |
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